
No. 26 Taishan Road
Suzhou New District
Suzhou Jiangsu
P.R. China



TAIYO INK (SUZHOU) CO., LTD.

Tel: +86-512-6665-5550

Fax: +86-512-6665-5057

Dual-component, alkaline developable

Liquid photo imageable solder mask

PSR-4000 MPHF / CA-40 MPHF

June. 2007

1. FEATURE:

PSR-4000 MPHF / CA-40 MPHF is a Photo imageable liquid solder mask ink (alkaline –developable type), designed for screen printing with below properties:

- * high photo speed and resolution
- * good thermal resistance
- * excellent resistance to gold plating (electro / electroless)
- * quick disappear of air bubble, no teardrops after printing
- * halogen-free

2. SPECTIFICATIONS:

Product name:	Main agent: PSR-4000 MPHF
	Hardener: CA-40 MPHF
UL Name	Main agent:PSR-4000EZ
	Hardener:CA-40DE
Color:	Main agent: Green
	Hardener: Milk white
Mixing ratio:	Main agent: Hardener = 70 : 30 (by wt.)
Viscosity after mixing	150±15dPa.s (Cone-plate viscometer 5min ⁻¹ /25°C)
Solid content:	78.0wt%
Tack dry window:	80°C×60min(Max)
Exposure:	500-700 mJ/cm ² (Under Mylar film)
	350-490 mJ/cm ² (On solder mask)
Postcure	150°C×60min
Pot life:	24 Hrs. (stored at dark & lustration place and closed, 25°C or below)
Shelf life:	180 days after production (stored at dark place, 20°C or below)

3. PROCESS CONDITIONS:

Process	Condition	Tolerance window
Test panels:	FR-4 (thickness 1.6mm)	-
Pretreatment:	Acid rinse → Buff scrubbing → Water rinse → Dry	-
Print:	100mesh	[100-120mesh]
Hold time	10 min	[10-20 min]
Pre-cure:	A: double side printing using pin and double side exposure or single side exposure	[80°C 60min] (Max)
	80°C 30min (Hot air convection oven)	
	B: two times printing and pre-cure for double side exposure	
	1 st : 80°C 15 min (Hot air convection oven)	
	2 nd : 80°C 25 min (Hot air convection oven)	
Exposure:	600 mJ/cm ² (Under Mylar film)	[500-700 mJ/cm ²]
	420 mJ/cm ² (On solder mask)	[350-490 mJ/cm ²]
	Halogen lamp 7kW (ORC HMW-680GW)	
Hold time:	10 min	[10-30 min]
Development:	Solution: 1wt% Na ₂ CO ₃	
	Temp. 30°C	
	Spray pressure 0.196Mpa	[0.196-0.245Mpa]
	Time: 60s	[60-90s]
Water rinse:	Temp. 25°C	[20-30°C]
	Spray pressure 0.1Mpa	[0.1-0.15Mpa]
	Time: 45s	[45-60s]
Post cure:	150°C 60 min (Hot air convection oven)	[150°C 30-90 min]

4. ATTENTION ON PROCESS:

- a) As to operation environment, it is necessary to control temperature, humidity and dust. Please use the yellow lamp or Ultraviolet ray filter .Do not use the white lamp or sunlight.
- b) Incompetent mixing will cause quality problem, such as gloss uneven and post cure problem.
- c) The optimum coating thickness is 20 to 30 μm (after curing); Thinner coating tends to lower the thermal and gold plating resistance. Thicker coating tends to longer cure time and impress when exposure.
- d) If the viscosity is too high to print, can use some solvent such as Diethylene Glycol Monoethyle Ether Acetate (Carbitol Acetate), the quantity of the solvent can not exceed 2%, (one Kg ink can add 20cc solvent at best), otherwise, it may cause teardrop or lower resistance to thermal and gold plating.
- e) As every plant's drying equipments, process condition and quality target is different, so the temperature and drying time may also have difference. Please do verification test to define the operating conditions.
- f) As every plant's exposure equipments, process condition and quality target is different, so the exposure energy and development time may also have difference. Please do verification test to define the operating conditions.
- g) Please adjust the development solution, temperature, spray pressure and time follow this data to decrease the undercut and get the excellent result.
- h) Insufficient cure of the ink can lower the thermal resistance, and excess cure can lower gold plating resistance. Furthermore, Curing condition of the solder mask ink should be defined together with the curing condition of the marking ink.

CA: Diethylene glycol monomethyl ether acetate (B.P 217 deg. C)

5. INK PROPERTIES:**5.1 TACK DRY WINDOWS:**

Drying time (80°C)	40min	50min	60min	70min
Developability	OK	OK	OK	NG

5.2 PHOTO SENSITIVITY:

Item	Thickness um	Under mylar film mJ/cm ²	On solder mask mJ/cm ²	Result
Sensitivity Kodak No.2	22±2	500	280	7step
		600	350	8step
		700	420	9step
Resolution Between QFP pads	40±2	500	280	50 um
		600	350	50 um
		700	420	50 um

(1 min development)

6. PROPERTIES:

Item	Teat Method	Result
Adhesion	Taiyo internal method Cross hatch peeling	100 / 100
Pencil hardness	Taiyo internal method No scratch on copper	7 H
Thermal resistance	Rosin flux 260°C/10sec, 3cycles	Passed
Acid resistance	10vol% H ₂ SO ₄ 20°C/20min. (Dip) Tape peeling test	Passed
Alkaline resistance	10wt% NaOH 20°C/20min. (Dip) Tape peeling test	Passed
Solvent resistance	PGM-Ac 20°C/30min. (Dip) Tape peeling test	Passed
Insulation resistance	IPC comb type (B pattern) Humidification: 25-65°C/90%RH/ DC100V Cycling for 7 days Measurement: DC500V 1min.	Initial 2.4×10 ¹² ohm Conditioned 3.0×10 ¹⁰ ohm
Dielectric constant	Taiyo internal method Values at 1MHz Humidification: 25-65°C/90%RH/ DC100V Cycling for 7 days	Initial 4.10 Conditioned 4.90
Dissipation factor	Taiyo internal method Values at 1MHz Humidification: 25-65°C/90%RH/ DC100V Cycling for 7 days	Initial 0.039 Conditioned 0.049
Electro gold plate	Internal lab test Ni 5um Au 1um	Passed
Electroless gold plate	Internal lab test Ni 3um Au 0.03um	Passed
Halogen content	By calculated	240ppm

Note:

- a) The above-mentioned data is based on TAIYO INK (SUZHOU) Company's laboratory test. As every plant's equipments, environment and parameters have difference, the data is only for your reference.
- b) Please work in accordance with MSDS.